

Title (en)  
AN APPARATUS FOR HIGH-THROUGHPUT PRODUCTION OF COAT MATERIAL ARRAYS, AND ANALYTICAL METHODS USING SUCH ARRAYS

Title (de)  
VORRICHTUNG ZUR HOCHDURCHSATZ-PRODUKTION VON BESCHICHTUNGSMATERIAL-ARRAYS UND ANALYTISCHE VERFAHREN ZUR VERWENDUNG SOLCHER ARRAYS

Title (fr)  
APPAREIL DESTINE A LA PRODUCTION A HAUT RENDEMENT DE RESEAUX DE MATERIAUX DE REVETEMENT, ET PROCEDES ANALYTIQUES UTILISANT CES RESEAUX

Publication  
**EP 1234173 A4 20050817 (EN)**

Application  
**EP 00974017 A 20001030**

Priority  

- US 0029854 W 20001030
- US 16234999 P 19991029

Abstract (en)  
[origin: WO0132320A1] A method of developing a new coating with desired performance characteristics (12), includes: (a) providing (13) an array of coating wells (14), each well configured for receiving a coating material having a known parameter; (b) placing (16) via an automated device (17) a coating material having the known parameter in each well (18), varying the parameter values in a plurality of wells; (c) correlating the value of the parameter for the coatings deposited in each of the wells with the position of the well in the array; (d) applying (19) a coating leveling force to the array to level the material in the wells via centrifuge (20), and optionally drying; (e) testing the coatings in the array to analyze (21) by detectors (5) the relationship between the position in the array and performance with regard to the property whereby the value of the parameter can be correlated (22) to the property performance, and the results entered in database (23), for selection for production (24). This screening method results in a substantial increase in the discovery rate of new coating materials.

IPC 1-7  
**G01N 31/00**; G01N 1/28; C12M 1/34; B01J 19/00; B01L 3/00; B05D 1/00; B05D 3/06; B05D 7/00; C09J 11/00; G01N 19/04; G01N 33/32

IPC 8 full level  
**G01N 33/48** (2006.01); **B01J 19/00** (2006.01); **B01L 3/00** (2006.01); **B05C 21/00** (2006.01); **B05D 1/00** (2006.01); **B05D 3/06** (2006.01); **B05D 3/12** (2006.01); **B05D 7/00** (2006.01); **C09J 11/00** (2006.01); **G01N 19/04** (2006.01); **G01N 33/32** (2006.01); **G01N 35/02** (2006.01); **G01N 37/00** (2006.01); **C07B 61/00** (2006.01); **C40B 40/14** (2006.01); **C40B 60/14** (2006.01); **G01N 35/00** (2006.01); **G01N 35/04** (2006.01)

CPC (source: EP)  
**B01J 19/0046** (2013.01); **B01L 3/505** (2013.01); **B01L 3/50853** (2013.01); **B05D 1/002** (2013.01); **B05D 3/067** (2013.01); **B05D 3/12** (2013.01); **B05D 7/00** (2013.01); **C09J 11/00** (2013.01); **G01N 19/04** (2013.01); **G01N 33/32** (2013.01); **B01J 2219/00315** (2013.01); **B01J 2219/00364** (2013.01); **B01J 2219/00443** (2013.01); **B01J 2219/00481** (2013.01); **B01J 2219/00587** (2013.01); **B01J 2219/00605** (2013.01); **B01J 2219/00621** (2013.01); **B01J 2219/00637** (2013.01); **B01J 2219/00691** (2013.01); **B01J 2219/00722** (2013.01); **B01J 2219/00756** (2013.01); **B01L 2300/0887** (2013.01); **B01L 2400/0409** (2013.01); **C07B 2200/11** (2013.01); **C40B 40/14** (2013.01); **C40B 60/14** (2013.01); **G01N 35/028** (2013.01); **G01N 2035/00534** (2013.01); **G01N 2035/0424** (2013.01)

Citation (search report)  

- [Y] US 3198657 A 19650803 - KIMBALL PHILIP D, et al
- [X] JACKMAN R J ET AL: "Using Elastomeric Membranes as Dry Resists and for Dry Lift-OFF", LANGMUIR, AMERICAN CHEMICAL SOCIETY, NEW YORK, NY, US, vol. 15, 13 April 1999 (1999-04-13), pages 2973 - 2984, XP002179004, ISSN: 0743-7463
- [Y] MCFARLAND E W ET AL: "Combinatorial approaches to materials discovery", TRENDS IN BIOTECHNOLOGY, ELSEVIER, AMSTERDAM, NL, vol. 17, no. 3, March 1999 (1999-03-01), pages 107 - 115, XP004157730, ISSN: 0167-7799
- See references of WO 0133211A1

Designated contracting state (EPC)  
AT BE CH CY DE ES FR GB IT LI

DOCDB simple family (publication)  
**WO 0132320 A1 20010510**; **WO 0132320 A9 20020815**; AU 1245401 A 20010514; AU 1447101 A 20010514; EP 1234173 A1 20020828; EP 1234173 A4 20050817; EP 1242192 A1 20020925; JP 2003513257 A 20030408; WO 0133211 A1 20010510

DOCDB simple family (application)  
**US 0029990 W 20001030**; AU 1245401 A 20001030; AU 1447101 A 20001030; EP 00974017 A 20001030; EP 00976736 A 20001030; JP 2001534517 A 20001030; US 0029854 W 20001030